

New developments of SiPM for visible and near UV light at FBK

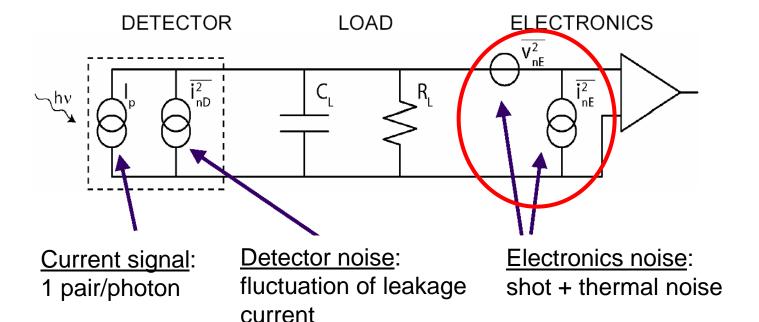
Alessandro Ferri





Internal gain

The problem: detection of extremely low intensity light down to the single photon



Need of a detector with internal amplification to reduce the impact of electronic noise.





PMT

Today, it is the most used sensor for low-level light detection.

Features:

- high gain
- single photon sensitivity
- low noise
- large sensitive area
- high frequency response
- good QE from UV to nearIR
- low cost



Issues:

- bulky and fragile
- influenced by magnetic fields
- damaged by high-level light

Applications:

physics experiments astronomy medicine biology material analysis

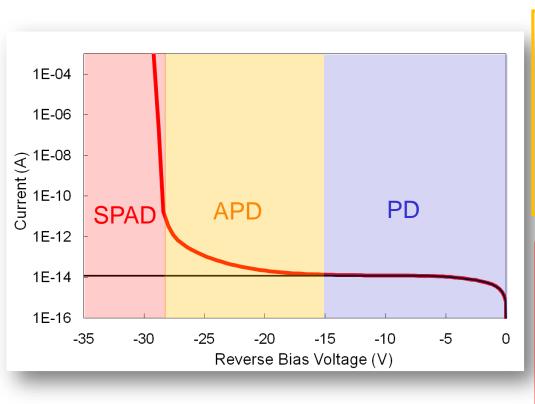
Difficult to compete with this technology!!





Solid-state technology: SPAD

Devices with internal gain based on carrier multiplication via impact ionization



AVALANCHE PHOTODIODE

- Gain ~100
- Timing ~ ns/ 10ph.e.
- Bias voltage ~500V
- Sensitivity ~10 ph. e.
- QE ~ high in all spectrum

SPAD / Geiger-mode APD

- Gain ~10⁶
- Timing ~ 10ps /10ph.e.
- Bias voltage <100V
- Sensitivity ~1 ph. e.
- QE ~ medium



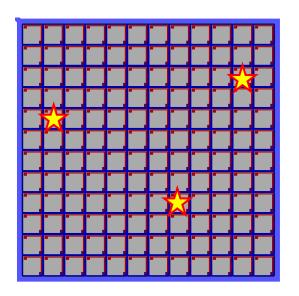


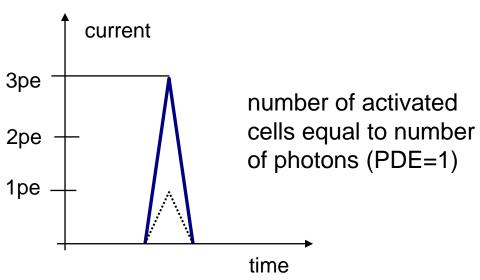
SPAD → SiPM

When the application requires (also) the estimation of the number of photons in a short light flash the SPAD is not enough.



SiPM: array of SPADs tightly packed and connected in parallel. (first proposed by Golovin and Sadygov in the '90s)









SPAD → SiPM

The transition from SPAD to SiPMs is not just design.

New <u>issues</u> are:

- a third factor enters in the photo-detection efficiency:
 the fill factor that for small cell size can be quite low
- how to control the dark rate because
 - limited space for gettering techniques
 - high probability to include noisy cells in a device
- optical cross-talk
- yield, uniformity





Main parameters

- Gain
 - Number of electrons per detected photon
- Primary Noise
 - Thermally generated events
- Correlated Noise
 - after-pulse, optical cross-talk
- Photo-detection efficiency (PDE)
 - Number of detected photons over total incident photons
- Dynamic range
 - Linearity of response
- Time resolution
 - Precision in the determination of photon arrival time





Wish list

Parameter	Wish	Comment
Gain	High	Usually not a problem (~1e6)
Primary Noise	Low	Hard to reach PMT levels!!
Correlated Noise	Low	Good options to reduce it
PDE	High	>50% feasible, wavelength?
Dynamic range	High	Up to 5-10000/mm2
Time resolution	Low	~100ps FWHM

➤ Today, we do not find a device with all the parameters optimized.

Trade-off among them (e.g. PDE vs dynamic range)!!





Other important features

(at the system level)

- Breakdown voltage uniformity
- Temperature stability
- Packaging type (dead border region, TSV)

COST!!

Solutions to improve performance must be cost-effective.





FBK experience





SiPM R&D



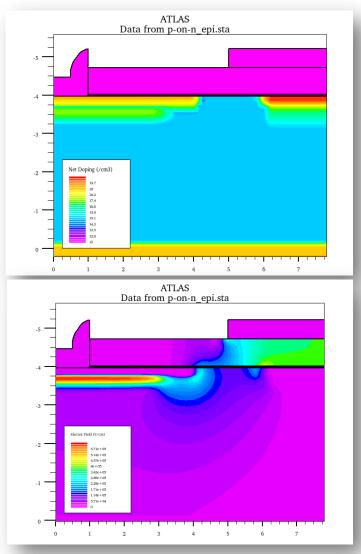
- Process/Device Simulation Layout
 1/2 people
- Process development and implementation
 2 people
- Device characterization4 people



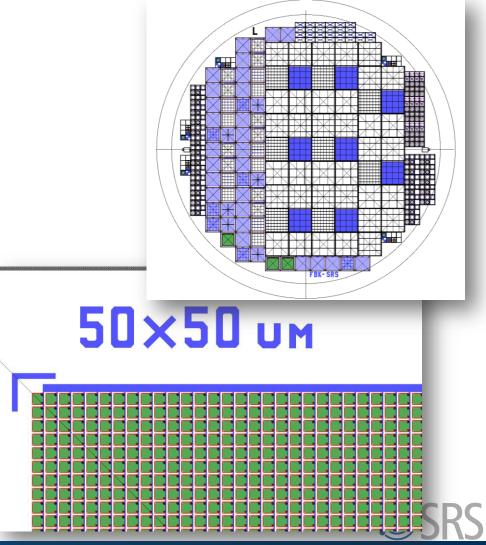


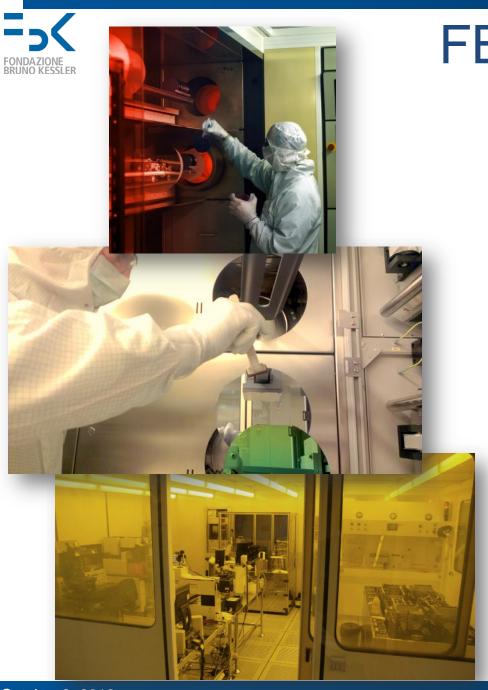
Simulation & Layout

TCAD for process and device



CAD for device design





FBK Technolgy

Clean room «Detectors»:

- 500m²
- 6" wafers
- Equipped with:
 - ion implanter
 - 8 furnaces
 - wet etching
 - dry etching
 - lithography
 - stepper
 - mask aligner
 - Deep RIE
 - Plasma-enhanced CVD
 - sputtering



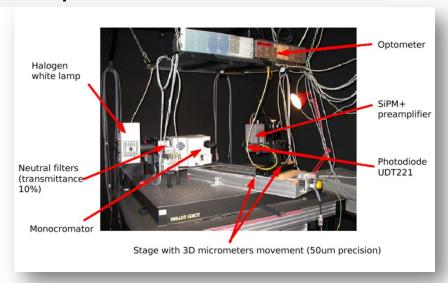


SiPM Characterization

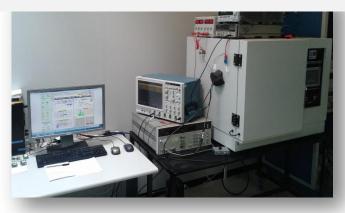
1. IV measurement



3. Optical characterization



2. Dark characterization



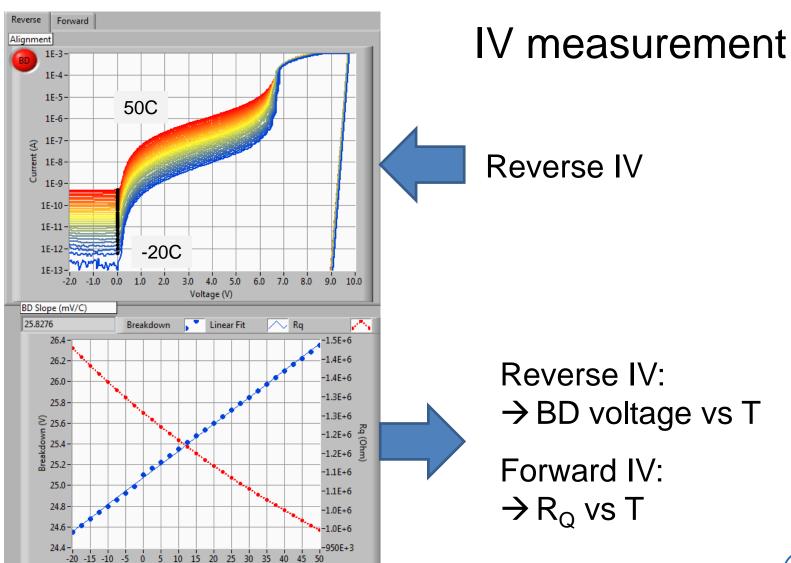
4. Functional charact.







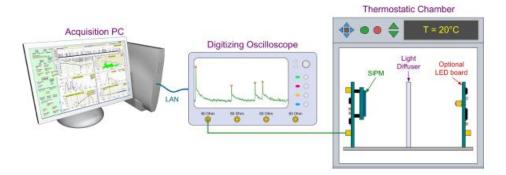
SiPM Characterization



Temperature (C)



Dark measurement

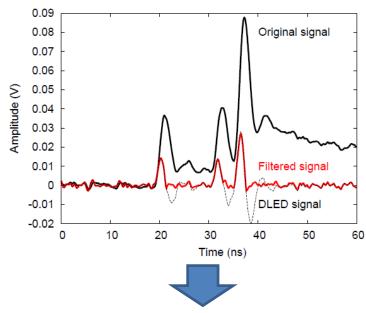


We acquire ms-long waveforms



Signal filtered to reduce its length



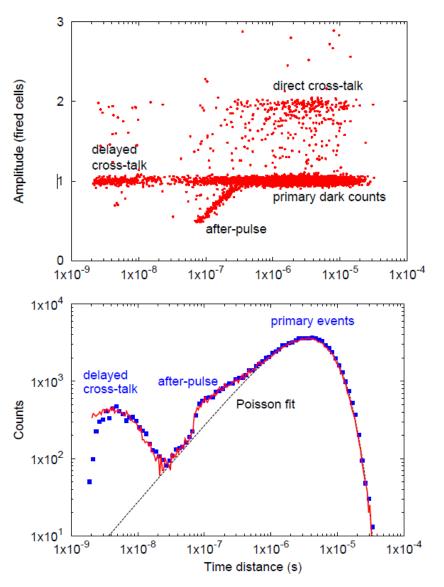


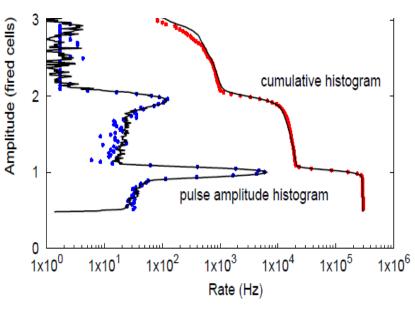
- → time delay array
- → amplitude array

October 6, 2013 SENSORS



Dark measurement





- → primary dark rate (DCR)
- → direct cross-talk
- → delayed correlated components



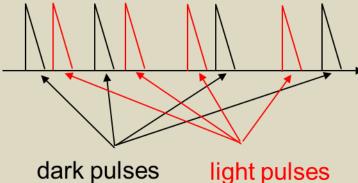


Optical characterization

Usually done on single-cell SiPM:

- less dark noise
- no optical cross-talk

photon counting under continous illumination



ight count rate - Poisson fit

Light count rate = Poisson fit (same program used in dark)

Light intensity determined with calibrated photodiode

pulsed mode with much less than 1 photon average

Light source = LEDs with different λ

Light inensity determined with a calibrated SPAD.

We count the positive events and compare with reference SPAD.

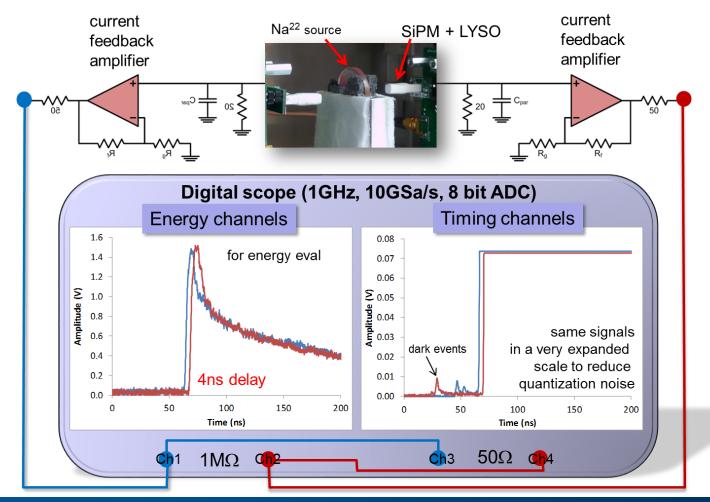
Very fast measurement, free form AP, can be done in climatic chamber.

October 6, 2013 SILICON RADIATIO SENSORS



Functional characterization

- gamma ray spectroscopy
- coincidence time measurement







FBK technology evolution

Original technology

2006

2010-11



RGB-SiPM

(Red-Green-Blue SiPM)

- excellent breakdown voltage uniformity
- low breakdown voltage temperature dependence
- higher efficiency
- > lower noise

electric field engineering

2012

RGB-SiPM HD

(Red-Green-Blue SiPM - high density)

- > small cell size with high fill factor:
 - high dynamic range
 - low excess noise factor

new cell border

2012

NUV-SiPM

(Near-UV SiPM)

new junction

- excellent breakdown voltage uniformity
- low breakdown voltage temperature dependence
- ▶ high efficiency in the near-ultraviolet
- > very low dark noise



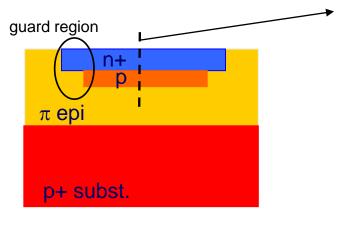


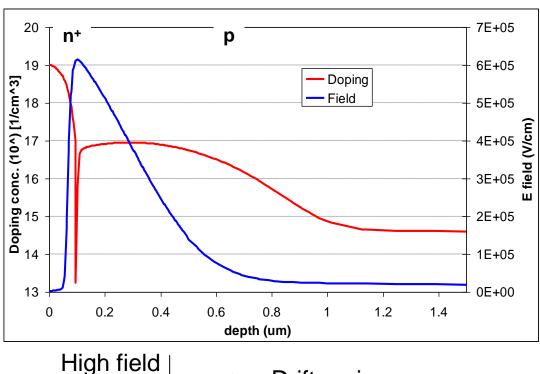
Original technology

[C. Piemonte
"A new Silicon Photomultiplier
structure for blue light detection"

NIMA 568 (2006) 224-232]

Shallow-Junction SiPM





Drift region

1) Substrate: p-type epitaxial

region

2) Very thin n+ layer

3) Polysilicon quenching resistance

4) high electric field





50um cell 45% FF

	Original n+/p	
Breakdown voltage	33V	
Breakdown voltage uniformity on wafer	~3V	
Max over-voltage	~8V	
V _{BD} temp. coeff.	75mV/C	
Max primary dark rate (20C)	several MHz/mm²	
Peak PDE	450-600nm	
Wavelength range	300-900	
Peak PDE	25%	
ECF (at max PDE)	1.5	

From measurements with scintillator: good energy and timing resolution!!

Main parameters



good gain temp. dependence even if VBD temp. dep. is not very small



Gain pulse: extracted from area of single cell signal
Gain current: extracted from ratio between DC current and primary dark rate

ECF = Gc/Gp





RGB

Re-design of the active area: electric field engineer.



Lower electric field, thicker high-field region + partially depleted epi at breakdown voltage

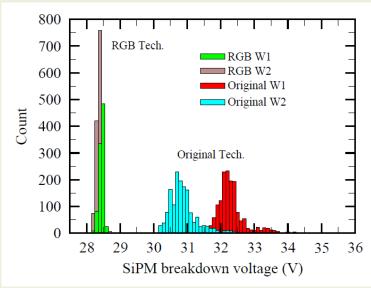
Next slide: comparison between two SiPMs 1x1mm2 50x50um2 having exactly the same layout (FF ~45%).

N.Serra: «Characterization of new FBK SiPM technology for visible light detection", JINST 2013 JINST 8 P03019



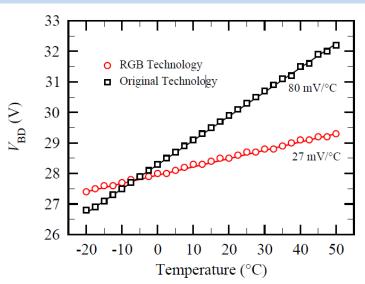


RGB: breakdown voltage

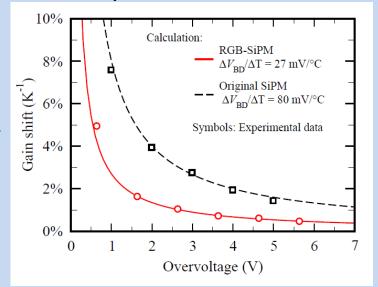


breakdown voltage non-uniformity strongly reduced both at wafer level and from wafer to wafer

breakdown voltage temperature dependence



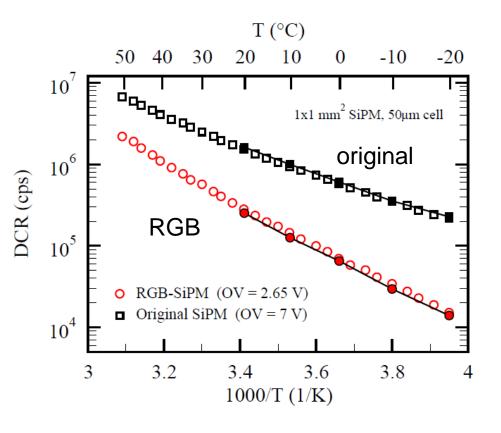








RGB: DCR



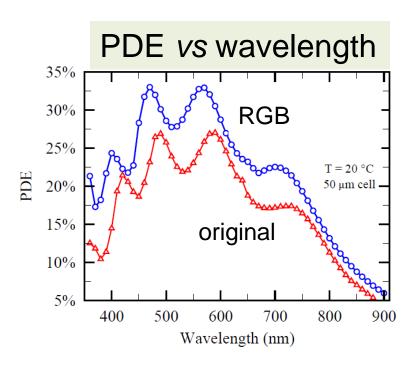
RGB has a much lower noise and a steeper temperature dependence:

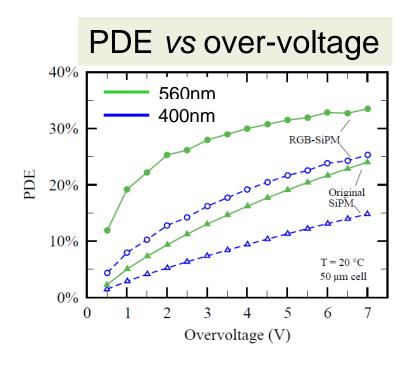
→ less tunneling





RGB: photo-detection efficinecy





RGB:

- → Much faster increase of efficiency vs over-voltage.
- → As in original, peak is at green, consistent with junction type





RGB vs original

	Original n+/p	RGB-SiPM (Upgraded n+/p)	
Breakdown voltage	33V	28V	
Breakdown voltage uniformity on wafer	~3V	<0.2V	
Max over-voltage	~8V	~6V	
V _{BD} temp. coeff.	75mV/C	25mV/C	
Max primary dark rate (20C)	several MHz/mm²	~500kHz/mm²	
Peak PDE	450-600nm	450-600nm	
Wavelength range	300-900	300-900	
Peak PDE	25%	33%	
ECF (at max PDE)	1.5	1.8	

50um cell 45% FF

From measurements with scintillator: comparable or slightly better for RGB





NUV SIPM

Same electric field configuration of RGB technology but with opposite sign.

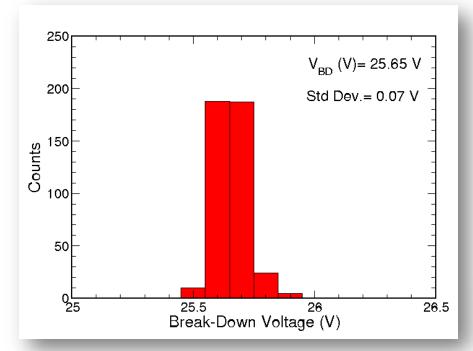


Objective: maintain the advantages of RGB but with peak efficiency in the near-UV



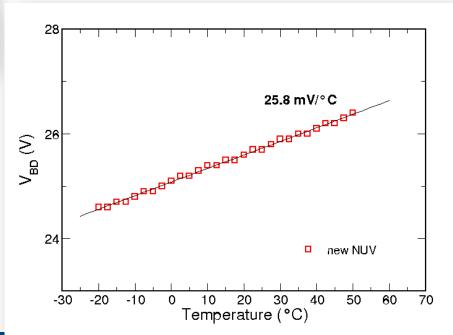


Breakdown voltage



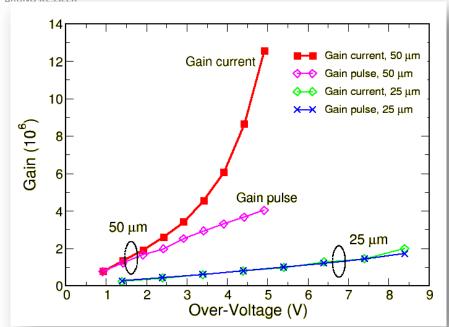
Breakdown voltage uniformity on a wafer.

Temperature dependence of the breakdown voltage.





Gain and noise

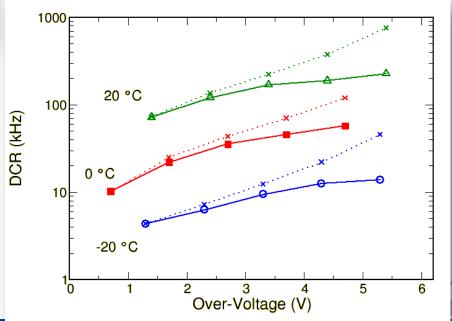


Gain of 50x50 and 25x25um² cells.

Gain pulse: extracted from area of single cell signal

Gain current: extracted from ratio between DC current and primary dark rate

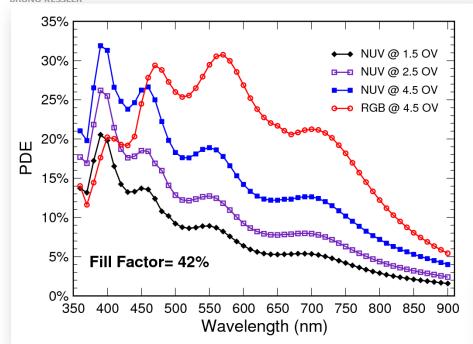
NUV-SiPM: 1x1mm² 50x50um². *Total* and *primary* dark count rate at 0.5 p.e.



October 6, 2013

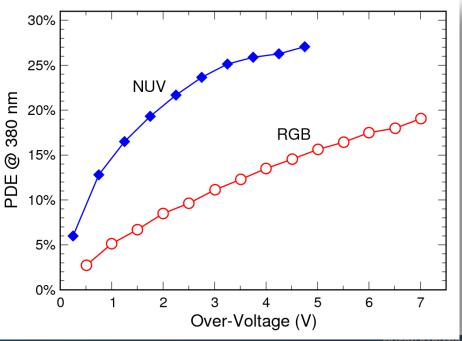


Photo-detection efficiency



PDE vs wavelength for a NUV-SiPM and RGB-SiPM with 50x50um² cell, 42% fill factor.

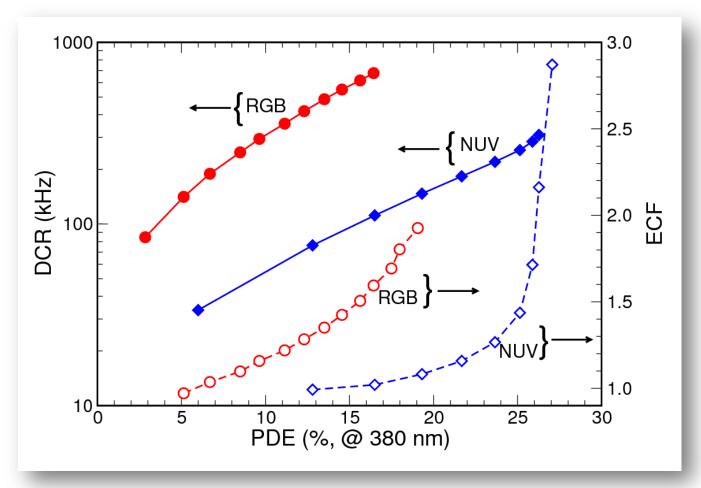
PDE@380nm vs Overvoltage for a NUV-SiPM and RGB-SiPM with 50x50um² cell, 42% fill factor.



October 6, 2013



Summary



ECF=Gain current
Gain pulse





NUV vs RGB

	Original n+/p	RGB-SiPM (Upgraded n+/p)		NUV-SiPM
Breakdown voltage	33V	28V		26V
Breakdown voltage uniformity on wafer	~3V	<0.2V		<0.2V
Max over-voltage	~8V	~6V		~5V
V _{BD} temp. coeff.	75mV/C	25mV/C		25mV/C
Max primary dark rate (20C)	several MHz/mm²	~500kHz/mm²		~150kHz/mm²
Peak PDE	450-600nm	450-600nm		390nm
Wavelength range	300-900	300-900		300-600
Peak PDE	25%	33%		32%
ECF (at max PDE)	1.5	1.8		2

50um cell 45% FF





What's next?

➤ Fill factor: 50x50um² cell only 45%

so far we used the mask aligner which has a limited alignment and resolution capability.

We produced functional devices with the «stepper» obtaining a fill factor of 65%...

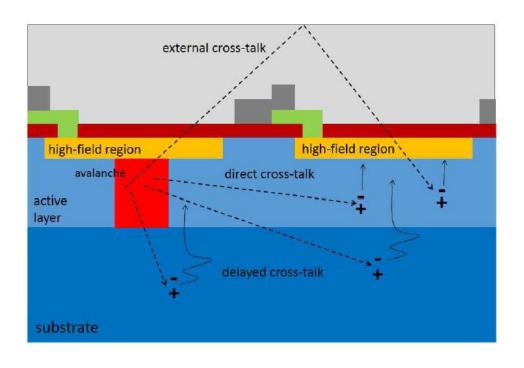
...good, but also the ECF is much higher!!

→ for higher PDE we <u>must</u> find a way to reduce optical cross-talk and after-pulsing





Correlated noise



Some paths for optical cross-talk

- Trenches to avoid direct and delayed cross-talk...
- buried junction to avoid out-diffusion...
- lower gain!





Small cells!

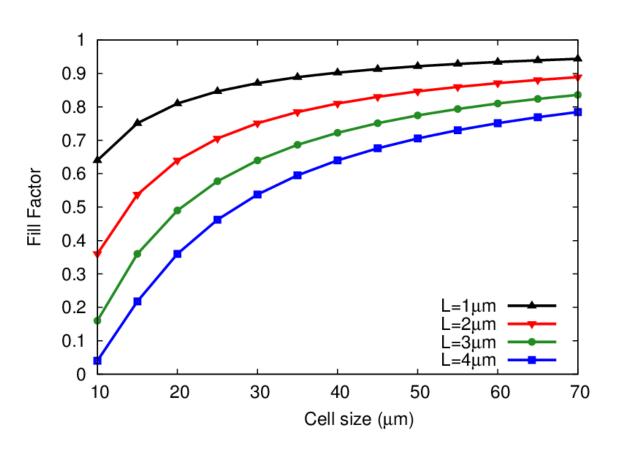
- 1. Lower correlated noise, because of lower gain:
 - lower after-pulse
 - lower direct and delayed OCT
 - lower external OCT
- 2. Higher dynamic range
- 3. Faster recharging time

All are important to optimize spectroscopic and timing performance, but not only...

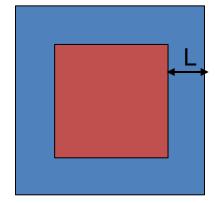




Difficult? Yes.



L is the dead border region around a cell

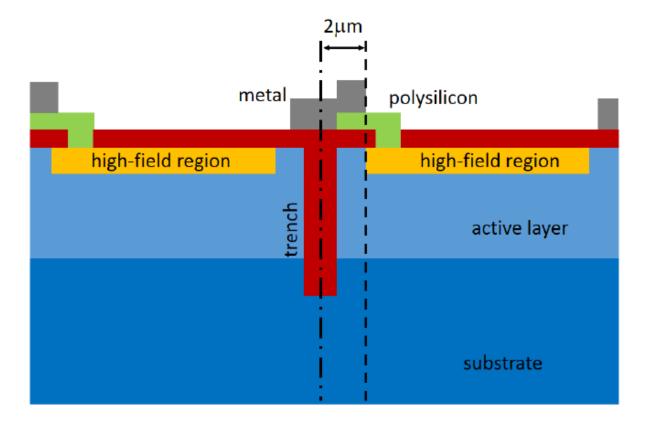






RGB-HD

We completely re-designed the cell border structure of RGB tech. to have small cells with high fill factor,



L = 2um. In the previous technology it was 6/7um



RGB-HD-SiPM

SiPM:

size: 4x4mm²

cell size: 30x30um²

cells: ~1000cells/mm²

Nominal FF = 74%

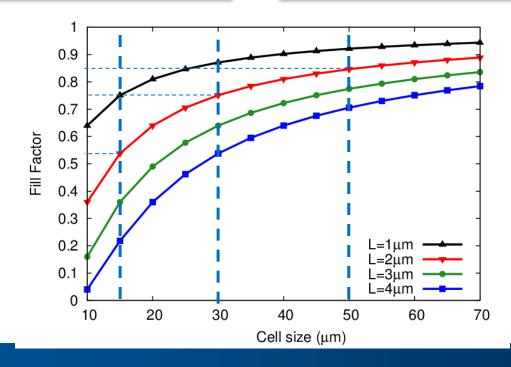
SiPM:

size: **2.2x2.2mm**²

cell size: 15x15um²

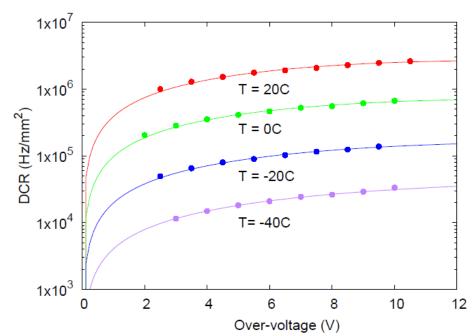
cells: 4400cells/mm²

Nominal FF = 48%







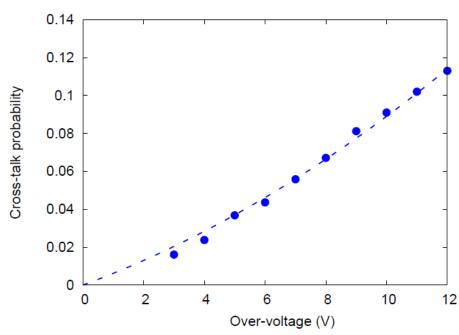


Dark rate 4 times higher than normal RGB.

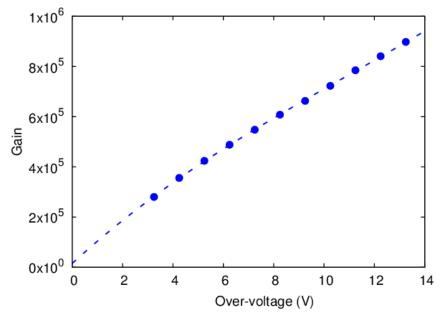
We have to check with further productions.

Low cross-talk. Very low AP prob. (~1%)

=> ENF ~1.1 at 10V

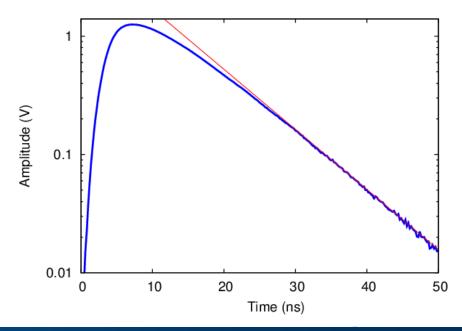






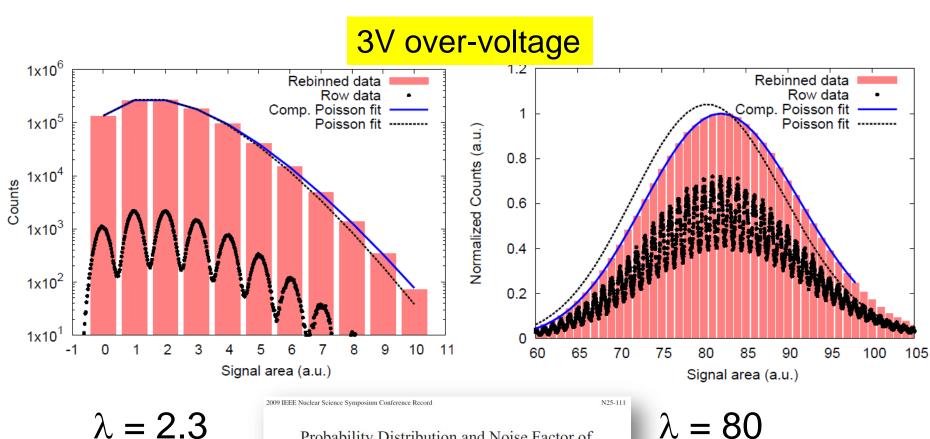
Gain always below 1 million

Recharge time constant of 9ns!! (With a quenching resistor of ~1Mohm)





SiPM irradiated with pulsed light from LED. Signal integrated for 100ns to include delayed correlated components



 $\lambda = 2.3$ p=2%

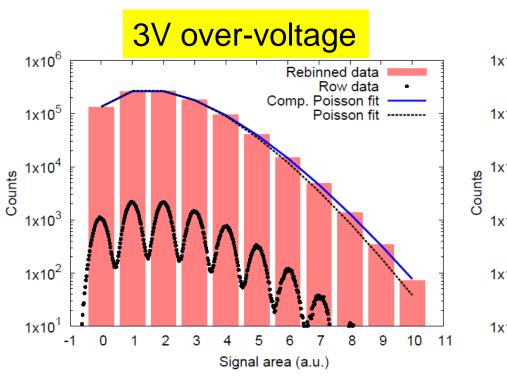
Probability Distribution and Noise Factor of Solid State Photomultiplier Signals with Cross-Talk and Afterpulsing

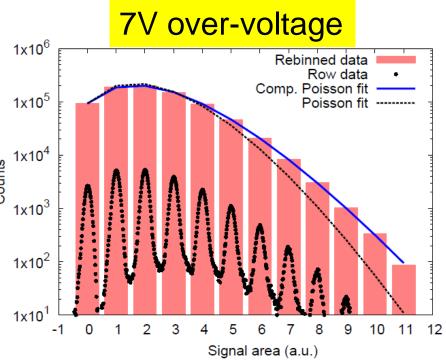
harpoonup = 2%





SiPM irradiated with pulsed light from LED.
Signal integrated for 100ns to include delayed correlated components





$$\lambda = 2.3$$
 p=2%

$$\lambda = 3$$
 p=7% SRS



SiPM irradiated with pulsed light from LED. Signal integrated for 100ns to include delayed correlated components

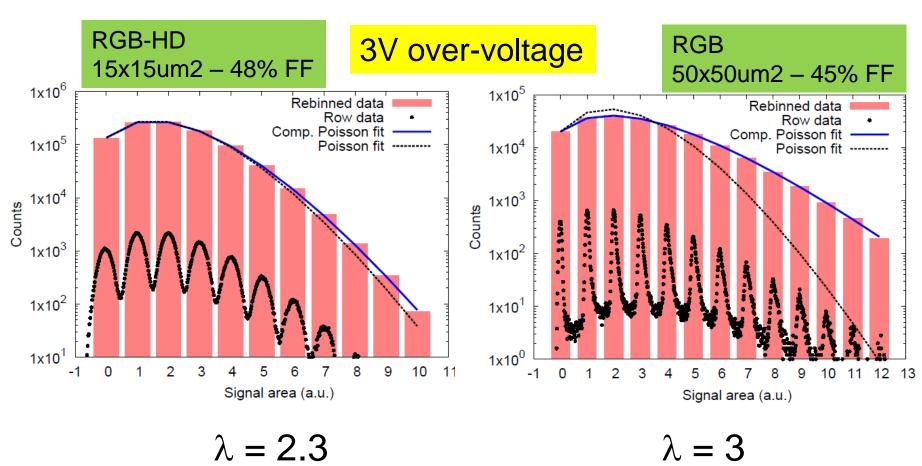
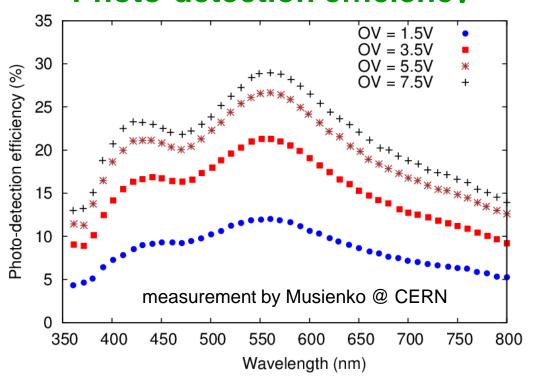




Photo-detection efficiency



Quenching resistor is high allowing high bias voltage.

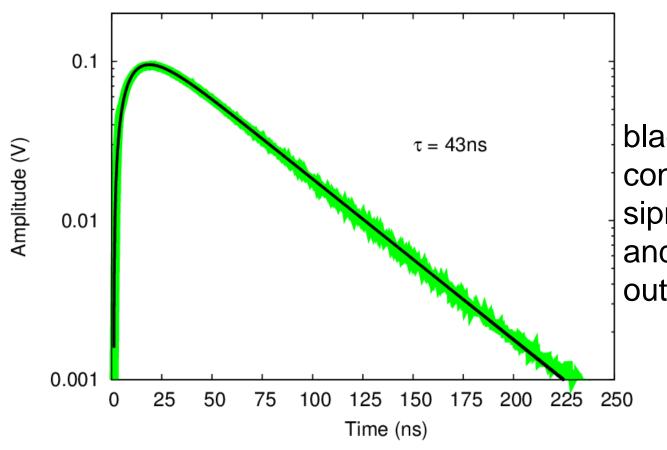
This make the device operation more stable in temperature.

- > PDE comparable to our old 50x50um2 cell!!
- Estimated PDE of 30um cell is ~50%!





Response to LYSO (511keV)

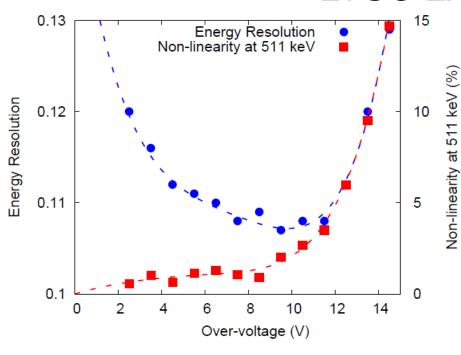


black line is the convolution of the sipm signal (tau=9ns) and LYSO light output (tau=43ns)



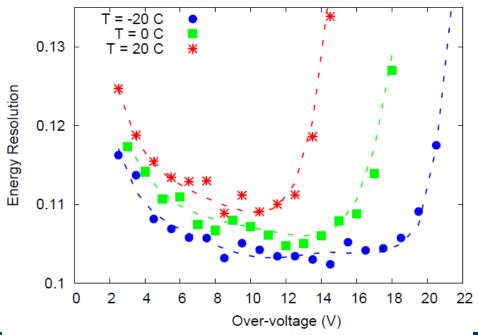


LYSO 2x2x10mm³



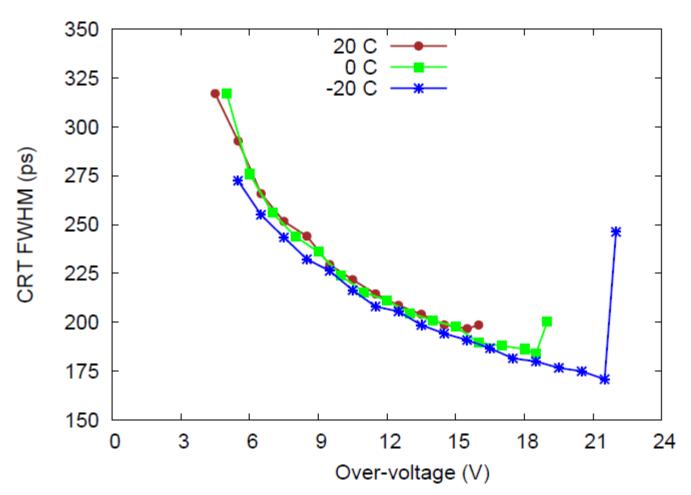
Non-linearity = deviation of the peak position from expected one (@ 511keV)

extremely wide operation range at low temperature, not limited by OCT.





LYSO 2x2x10mm³





NUV vs RGB

	Original n+/p	RGB-SiPM New n+/p	RGB-HD- SiPM New n+/p	NUV-SiPM p+/n
Cell size	50µm	50µm	15µm	50 μm
Breakdown voltage	33V	28V	28V	26V
Breakdown voltage uniformity on wafer	~3V	<0.2V	<0.2V	<0.2V
Max over-voltage	~8V	~6V	~8V	~5V
V _{BD} temp. coeff.	75mV/C	25mV/C	25mV/C	25mV/C
Max primary dark rate (20C)	several MHz/mm²	~500kHz/mm²	~2MHz/mm²	~150kHz/mm²
Typical FF	45%	45%	48%	45%
Peak PDE	450-600nm	450-600nm	450-600nm	390nm
Wavelength range	300-900	300-900	300-900	300-600
Maximum PDE	25%	33%	30%	32%
ECF (at max PDE)	1.5	1.8	1.1	2





Conclusion

SiPM technology is evolving quickly.

It outclasses PMT in many aspects except from dark count rate.

High competition: → better performance

→ lower price

